Measurement Of Depletion Voltage
And Leakage Current For
Silicon Strip Detectors

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Abstract

Apparatus was assembled to measure the capacitance of, and current drawn by, a silicon strip diode detector over a range of applied reverse biased voltages. It was tested by using a variety of simple circuit components and simple diodes whose characteristics were known. The depletion voltage of the diodes was measured using values of capacitance measured over the range of voltages supplied.

National Instruments Labview software was used to control the measurements in an automated routine designed, in part, by this author.

Capacitances were measured using a digital LCR meter manufactured by Hewlett Packard (HP2842A). These values were taken at a range of LCR meter voltages and at frequencies of 10 kHz, 100 kHz and 1 MHz. Voltage biases were supplied and currents were measured using a Keithley 237 (a precision voltage and current supply).

Two different silicon strip devices were measured. The depletion voltage was measured using one strip from each device and found to be 20 ± 1 V for the first and 57 ± 1 V for the second. The corresponding leakage currents were 4.5 nA and 1.43 μA.

One silicon diode was measured before and after it was glued to a base plate with thermally conducting glue. The gluing did not effect the depletion voltage significantly. It did, however, effect the leakage current. This affect was greater at higher voltages.
Declaration

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Further information on the conditions under which disclosures and exploitation may take place is available from the Head of Department of Physics and Astronomy.
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Do nothing that is of no use.

- Miyamoto Musashi, Go Rin No Sho.
Chapter 1

Introduction

1.1 Physics at LHC

Theorists are dreaming up ideas continuously trying to describe nature. In particle physics, experimentalists are trying to devise ways to test these theories. The Large Hadron Collider has been planned and its components are currently being put together. LHC proposes to accelerate proton bunches to collide with each other at a centre of mass energy of 14 TeV.

1.1.1 ATLAS

ATLAS is one of the experiments being developed for LHC. The characteristics of ATLAS’s silicon components require the experiment to run with a maximum period of 25 ns between bunches of protons crossing.

ATLAS will consist of a solenoid and air-cored toroids (all superconducting) a muon spectrometer, hadronic and electro-magnetic calorimeters both forward and barrel. It will have an inner detector with straw, silicon pixel and silicon strip detectors. A schematic of ATLAS is shown in figure 1.1.
The Silicon Tracking Detector is located at the centre.

Figure 1.1: The ATLAS detector
1.1.2 ATLAS Searches

ATLAS will investigate CP violation in b physics, the top quark and compositeness of fermions. It also hopes to look for SUSY, Higgs and heavy W and Z type bosons.

1.1.3 Manchester Involvement

Manchester University is currently involved with one ATLAS project which is split into two areas. The first is the design of thermal imaging for silicon strip modules and is not covered by this thesis. Manchester is also involved with the gluing assembly of the forward silicon strip modules for which this research will serve a purpose.

1.2 This Thesis

This thesis describes the methods of use, and results taken, from a silicon module probe station. The measurements of capacitance and leakage current have been tested on progressively more complex circuits and ultimately on silicon diodes. This thesis also looks at the results from the gluing process.

1.2.1 Thesis Structure

Chapter 2 presents the basics of semiconductor physics with silicon detectors in mind. General electronic properties are discussed and a method for measuring depletion voltage is described.

Chapter 3 contains the information required to introduce the reader to the workings of the Keithley 237, the HP4284A, and the guard box which was constructed here. These devices are the major hardware of this project and much work has gone into the understanding of them.

Chapter 4 covers the computer interfacing with the devices above. To operate these it was necessary to write computer code. Both the Keithley 237 and the HP4284A came with code to run in Labview for remote operation so this language
seemed the most suitable to continue with. Some of the more important features of the code are explained in this chapter.

Chapter 5 shows the experimental set-up and discusses the practical aspects of obtaining data for leakage current and depletion voltage measurements.

Chapter 6 presents data for the examination of the probe station's behaviour. It then goes on to show the method for extracting values of depletion voltage and leakage current. Finally, chapter 6 presents the analyses of data from basic silicon diodes, glued diodes and strip diodes.
Chapter 2

Theory of Semiconductor Diode Detectors

This thesis reports the measurement of leakage current and depletion voltage in silicon strip detectors. The essentials of semiconductor physics are reviewed in sections 2.1 and 2.2.

A basic version of the diode detector is described in section 2.3. Section 2.4 discusses the ATLAS diode detector's key points. Section 2.5 discusses some of the difficulties encountered during the research and development of the ATLAS detectors.

There is a choice of semiconductor that can be used. ATLAS has decided to use silicon.

2.1 Types of Doping

Doping is a process carried out on an intrinsic semiconductor. An intrinsic semiconductor has a crystal structure which is as near to pure as possible.

There are two types of doping. One of these creates an electron rich crystal, and the other an electron deficient crystal.
The doping process is where an impurity is set into an intrinsic semiconductor (ie silicon), replacing one of its silicon atoms with that impurity. The material produced by substituting a group V element is said to be n-type and the element replacing the silicon is called a donor. The material produced with a group III element is p-type and the substitution element is an acceptor.

The number of donors in n-type exceeds the number of acceptors and therefore the material contains more electrons than the pure crystal. In p-type the number of acceptors exceed the number of donors and so the material has an excess of 'holes'.

2.2 Diode

To understand the diode, it is useful to imagine that it is possible to bring the two types of doped semiconductor together and form a continuous crystal. (In reality a layer of one type of silicon is allowed to diffuse across the other making a gradual change from n-type to p-type). At this new junction the electrons in the n-type region 'see' the holes in the p-type. If the electrons move into these holes, they bind. These electrons are no longer free to move, except for a small dissociation. The electrons are now in the valence band, an energy level approximately 1 eV more stable than a freely conducting band. This is clearly an energetically favourable situation. However, as the electrons move across to these holes a potential builds up. At some point the energy required to move the electrons to the holes against this potential exceeds the energy difference between the two states. The p-n junction then forms a steady state.

2.2.1 Depletion

The steady state contains a depletion region. This is a region with no free charge carriers. All the electrons have annihilated with all the holes in this region.

The depletion region can be increased in size by the application of a reverse bias, that is a potential difference applied across the junction with the n-type most positive.
CHAPTER 2. THEORY OF SEMICONDUCTOR DIODE DETECTORS

Assume the number of acceptors in the p region per unit cross-sectional area does not vary with depth ($x$) and the same for the donors in the n region (figure 2.1 a). In this case, the charge density varies as shown in figure 2.1 b. Notice the lack of free charge carriers around the junction (the depletion region). Due to the movement of electrons and holes to form the equilibrium, the charge density is

\[
\rho(x) = \begin{cases} 
-eN_A & \text{for } -w_p < x < 0 \\
+eN_D & \text{for } 0 > x > w_n \\
0 & \text{elsewhere}
\end{cases},
\]

where $N_A$ is the number of acceptors and $N_D$ is the number of donors per cubic metre. This can be seen in figure 2.1 c. Integrating this gives the electric field (figure 2.1 d),

\[
E = -\frac{d\phi}{dx} = \begin{cases} 
\frac{-eN_A}{\varepsilon \varepsilon_0} (x + w_p) & \text{for } -w_p < x < 0 \\
\frac{eN_D}{\varepsilon \varepsilon_0} (x - w_n) & \text{for } 0 > x > -w_n \\
0 & \text{elsewhere}
\end{cases}.
\]

Finally, integrating again shows the voltage profile across the junction,

\[
\phi(x) = \begin{cases} 
0 & \text{for } x < -w_p \\
\frac{eN_A}{2\varepsilon \varepsilon_0} (x + w_p)^2 & \text{for } -w_p < x < 0 \\
\Delta \phi_0 - \frac{eN_D}{2\varepsilon \varepsilon_0} (x - w_n)^2 & \text{for } 0 > x > -w_n \\
\Delta \phi_0 & \text{for } x > w_n
\end{cases},
\]

shown in figure 2.1 e.

Given that the net charge in the diode is zero the electric field on both sides of the diode must cancel,

\[eN_A w_p = eN_D w_n.\]

Thus the depletion depths $w_n$ and $w_p$ are:

\[w_n = \left(\frac{2\varepsilon \varepsilon_0 N_A \Delta \phi_0}{e N_D(N_A + N_D)}\right)^\frac{1}{2},\]  \hspace{1cm} (2.5)

and

\[w_p = \left(\frac{2\varepsilon \varepsilon_0 N_D \Delta \phi_0}{e N_A(N_A + N_D)}\right)^\frac{1}{2}.\]  \hspace{1cm} (2.6)
Figure 2.1: The p-n junction with zero applied bias [1].
CHAPTER 2. THEORY OF SEMICONDUCTOR DIODE DETECTORS

2.2.2 Bias

When a potential difference $V_{Bias}$, is placed across the diode one way it conducts well. Placed the other way it insulates well (except when breakdown occurs). The depletion region is highly resistive compared to the rest of the silicon, so nearly all the potential difference drops across this region.

If a positive potential difference, which is greater than $\Delta \phi_0$ needed to match and remove the depletion layer, is applied across the diode then the diode conducts and is said to be forward biased.

If, on the other hand, the diode is reverse biased the applied potential difference is added to $\Delta \phi_0$ and the depth of the depletion layer increases, see figure 2.2 for the I-V characteristics.

This figure shows the current drawn by a diode when different biases are applied. In the forward bias region, with a potential difference exceeding $\Delta \phi_0$, the diode conducts. In the reverse bias region it insulates. However, whilst insulating there is a very tiny current drawn by the diode. This is called the leakage current and is too small to be shown here.

Figure 2.2: Current vs Potential Difference across a diode [1].
CHAPTER 2. THEORY OF SEMICONDUCTOR DIODE DETECTORS

The sizes of the depletion layers are now given by [1],

\[ w_n = \left( \frac{2\epsilon_\infty N_A (\Delta \phi_0 - V_{Bias})}{e N_D (N_A + N_D)} \right)^{\frac{1}{2}} \]  
(2.7)

and,

\[ w_p = \left( \frac{2\epsilon_\infty N_D (\Delta \phi_0 - V_{Bias})}{e N_A (N_A + N_D)} \right)^{\frac{1}{2}} . \]  
(2.8)

2.2.3 Capacitance

When the diode is reverse biased it has a capacitance. This is due to the lack of charge carriers turning the depletion region into an insulating dielectric. Its capacitance varies with its geometry and the relative permittivity (\( \epsilon \)) of the semiconductor.

At room temperature \( \epsilon \) for silicon is 11.8 [2]. The diodes covered in this thesis can all be approximated to some form of parallel plate geometry.

The capacitance of a parallel plate capacitor is

\[ C = \epsilon C_0 = \frac{\epsilon_\infty A}{D} , \]  
(2.9)

where \( A \) is the area of the plate and \( D \) is the separation [3]. We can apply this to the diode. The build-up of charge due to the equilibrium settled at translates into a surface charge on the capacitor,

\[ d\sigma = \begin{cases} 
  e N_D d w_n & \text{for } x < 0 \\
  e N_A d w_p & \text{for } x > 0 
\end{cases} . \]  
(2.10)

Thus the capacitance of the diode in reverse bias mode per unit area is

\[ C = \left| \frac{d\sigma}{dV} \right| = e N_D \left| \frac{d w_n}{dV} \right| = \left( \frac{\epsilon_\infty e N_A N_D}{2(N_A + N_D)(\Delta \phi_0 - V_{Bias})} \right)^{\frac{1}{2}} . \]  
(2.11)

If the total number of donors and acceptors is \( N \), where \( \frac{N}{2} = N_A = N_D \), this reduces to

\[ C = \left( \frac{\epsilon_\infty e N}{8V} \right)^{\frac{1}{2}} . \]  
(2.12)
It can now be seen that the capacitance varies with voltage:

\[ C \propto \begin{cases} \frac{1}{\sqrt{V_{Bias}}} & \text{for } V_{Bias} < V_{Dep} \\ \text{Constant} & \text{for } V_{Bias} > V_{Dep} \end{cases} \]  

(2.13)

This is a property with which to measure \( V_{Dep} \), the depletion voltage.

### 2.3 Diode Detector

The silicon detector devices are about 12 cm long by 6 cm wide and are made up from silicon trapezium wafers measuring approximately 6 cm square. Their bulk is n-type. To these, micro-strips of p-type have been added. The strips are typically 10 microns across and travel along the length of each 6 cm block.

Due to the small size of the p-type strips, the number of acceptor sites per unit volume is increased by a large factor and the substrate is called p\(^{+}\)-type. Any depletion region in the p\(^{+}\)-type is much smaller than in the n-type. This allows full depletion of the n region.

The relationship between the bias voltage \( (V_{Bias}) \) and the size of the depletion, \( x \) (where \( x = w_n + w_p \)), for a silicon strip detector is given by

\[ V_{Bias} = \frac{eN}{2\epsilon \epsilon_0} x^2 [4]. \]  

(2.14)

In the notation of this thesis, taking into account the p\(^{+}\)-type meaning that \( w_p \ll w_n \), this becomes:

\[ V_{Bias} = \frac{eN}{2\epsilon \epsilon_0} w_n^2 \]  

(2.15)

from equation 2.7, where \( N \) is the number of carriers per unit volume (section 2.2.3).

### 2.3.1 Hole Electron Pair Production

When an energetic charged particle travels through a depleted region it promotes electrons into the conduction band and consequently it creates holes in the valence band. The probability of recombination is small as all the acceptor and donor sites are occupied. The electron and hole move in opposite directions towards the edge of the depleted region. This is because the depletion region sustains an electric field.
2.3.2 Detection

If the diode is fully depleted the electron and hole will not find partners to annihilate with. Being influenced by the potential difference they will move. Their motion constitutes a current towards the bias voltage supply. It is this that can be detected by the detector's electronics. There are many electron hole pairs produced per particle due to the amount of energy deposited, about 25000 in 300 microns of silicon for a minimum ionising particle.

2.4 ATLAS Diode Detector

The ATLAS SCT Diode Strip Detector is shown in figure 2.3.

The strips, located on the trapezium silicon wafers, travel down the page.

Figure 2.3: The SCT detector module[5]
It consists of three sections (see figure 2.4): the hybrid, which contains the electronics (top left); the beryllia plate, for thermal conductivity and mechanical strength (bottom); and the silicon strip diodes (top right).

Figure 2.4: The SCT detector module separated into its components [5].

2.4.1 Type of Silicon Used

The silicon used here is not electronics grade. It has been specially manufactured by Hamamatsu for high resistivity. Resistivity is increased by using a lower doping concentration to that of ordinary silicon. The detector’s size is limited by the size of industrial ingots. These are circular and about 10 cm in diameter.

2.4.2 Stereo Angle

The detector has two pairs of silicon wafers, one on each side. They are rotated by 40 mrad with respect to each other.

If two particles pass through one strip at two different places there will be two readings the location of which cannot be determined. The stereo angle serves to locate how far along the strip each particle passes, with some lesser accuracy than the primary coordinate. The accurate reading is chosen to be the one perpendicular to the magnetic field and the direction of motion. This is because the curvature of
the particle's flight path, due to the magnetic field, leads to the measurement of its momentum.

The smallness of the skew angle ensures that both plates get an accurate reading of the important component of the particles position.

2.4.3 Beryllia

Beryllia is the compound beryllium oxide, BeO. It was chosen as the skeletal component of the device as it has low Z, has a long radiation length, is of low density, is mechanically stable and conducts heat well.

2.4.4 Hybrid

The hybrid is the part of the module where the preliminary electronics are located. The electrical activity in the hybrid generates a lot of heat so it is separated from the detector except for a small junction where the cooling pipe has access. This limits the transfer of heat to the silicon strips. In doing so, it reduces the effects of radiation damage (section 2.5.3).

2.5 ATLAS Diode Problems & Solutions

2.5.1 Radiation Levels

The radiation level through the silicon detectors is expected to be $2.2 \times 10^{13}$ 1 MeV neutron equivalents per square cm per year [6]. It is at energies of about 1 MeV that neutrons start to damage silicon. Therefore the silicon detectors must stand up to severe radiation environments.
2.5.2 Radiation Effects

There has been much research into the effect of radiation on silicon detectors. It seems that high fluences cause problems. The bombardment of silicon atoms by neutral and charged particles in the crystal causes the structure to change. This is termed "Bulk Damage".

It has been observed that, during irradiation, the n-type region mutates gradually into p-type. This effective dopant concentration change may result from three processes: donor removal, prompt acceptor creation, and the creation of electrically inactive regions which after a time become active [7], [8]. The latter is known as reverse annealing.

This donor removal, or reduction in n-type carriers, has the disadvantage that the bias voltage must be increased as time goes by, to create a full depletion (see equation 2.15). Also, when the silicon reaches the stage where it becomes all p-type then it is impossible to create any depletion.

2.5.3 Thermal Annealing

Further research into the problem of annealing found that at low temperatures the reverse annealing caused by radiation, was affected. Exposing the silicon at low temperature reduces the damage. Simulations at temperatures of 0°C, −5°C and −10°C found large differences in operation between −5°C and 0°C [9].

However, even after irradiation the silicon must be kept cool. The reverse annealing process mentioned above is the only long term effect. It reintroduces itself at higher temperatures and is not beneficial as the short term annealing can be.

This thesis does not approach the method for low temperature testing. For such testing, methods must be incorporated to reduce the level of water vapour in the gas surrounding the silicon. Below about 5°C, when using air from the surroundings, condensation starts to form on the apparatus.
Chapter 3

Electronic Devices Used

Measurements of capacitance and current, for a range of voltages, are required to determine the leakage current and depletion voltage of the diodes which will ultimately be measured. Equation 2.13 provides the relationship needed between $V_{Bias}$ and $C$, which changes at $V_{Dep}$.

This chapter aims to introduce the workings of the electronic devices used in this project. These devices constitute a large part of the full experimental set-up, which is described in chapter 5.

The LCR meter and the voltage supply are used simultaneously to save time. The Keithley 237 supplies a voltage across the sample, which will ultimately be the silicon detector wafer. While this voltage is supplied there is a delay and then two measurements are made. The Keithley 237 measures the current, then the LCR-meter measures the complex impedance.

The Keithley Model 237 High Voltage Source Measure Unit [10], Hewlett Packard HP4284A Precision LCR Meter [11] and the sample load being measured will hereafter be referred to as the Keithley, the HP, and the DUT respectively. (DUT stands for device under test).
3.1 The Keithley

The Keithley is a precision device supplying high voltage whilst measuring current or vice versa. It was chosen for its voltage-supplying capabilities. It can deliver a potential difference across its terminals of up to 1100V. At the same time it measures the current drawn through the DUT which is placed across these terminals. It is capable of measuring currents between 10 fA and 100 mA when sourcing less than ±110V.

The Keithley is a complex combination of digital and analogue electronics. These components have been conveniently separated by the manufacturer to avoid interference between the two sections.

3.1.1 Extraordinary Measurement Care

Due to the nature and range of measurements that the Keithley is required to cope with it is necessary to protect against bad results caused by losses in the cables. The main losses are those associated with low resistance DUTs and very high resistance DUTs. Measurement of diode characteristics can be prone to both.

3.1.2 High Resistance DUTs

In the high resistance DUT case, the resistance, $R_L$, of the insulative dielectric in standard coaxial cable is of the order 100 GΩ (see figure 3.1).

![Coaxial cable circuit](image)

Figure 3.1: Coaxial cable circuit [10].
If the DUT's resistance is 1 GΩ this will cause leakage of about 1% through the coaxial cable. It is therefore necessary to use triaxial cable (figure 3.2).

![Triaxial cable circuit](image)

Figure 3.2: Triaxial cable circuit [10].

Triaxial cable has one core and two concentric shields. The central core carries the supply voltage. The innermost shield carries the same potential to within ±2 mV. This is linked to a buffered voltage supply in the Keithley. The outermost shield is connected to earth.

Only a small potential difference is present in the cable between the inner shield and the core. This drastically reduces the parallel current loss through the cable's cladding i.e. there is no leakage current through the cable's dielectric. The low potential end does not require such shielding.

### 3.1.3 Low Resistance DUTs

The Keithley constantly monitors and readjusts its output. During a standard ("Local Sense") measurement, the terminal potential difference is measured and the result is fed back to the voltage source. The consequence is that the terminals are continuously monitored and a highly accurate potential difference is produced across them. However, when a measurement of a low resistance DUT is taken, the cables will see a significant potential difference across them. This will obviously reduce that seen by the DUT. To combat this a "Remote Sense" option is supplied. A triaxial cable identical to the one connected to the high potential terminal is added. This time the core is linked directly from the feedback circuit to the high potential end of the DUT. If the low potential end is connected using a triaxial cable the redundant
inner shield can be used to carry the low potential sense terminal to the DUT’s low potential end. The remote feedback circuit is then complete (see figure 3.3).

### 3.1.4 Resolution

The resolution of the Keithley depends on the compliance (compliance is the term used by Hewlett Packard to mean current limit, see section 3.1.6). This dependance is shown in table 3.1.

<table>
<thead>
<tr>
<th>RANGE</th>
<th>RESOLUTION</th>
</tr>
</thead>
<tbody>
<tr>
<td>1 nA</td>
<td>100 fA</td>
</tr>
<tr>
<td>10 nA</td>
<td>1 pA</td>
</tr>
<tr>
<td>100 nA</td>
<td>10 pA</td>
</tr>
<tr>
<td>1 uA</td>
<td>100 pA</td>
</tr>
<tr>
<td>10 uA</td>
<td>1 nA</td>
</tr>
<tr>
<td>100 uA</td>
<td>10 nA</td>
</tr>
<tr>
<td>1 mA</td>
<td>100 nA</td>
</tr>
<tr>
<td>10 mA</td>
<td>1 uA</td>
</tr>
<tr>
<td>100 mA</td>
<td>10 uA</td>
</tr>
</tbody>
</table>

Table 3.1: Resolution of Keithley readings

### 3.1.5 Voltage Supply

The voltage supplied can be varied from $-1100$ V to $+1100$ V. This is in steps of $100 \, \mu$V for less than $\pm 1.1$ V, $1$ mV for less than $\pm 11$ V, $10$ mV for less than $\pm 110$ V, and $100$ mV for less than $\pm 1100$ V.
Figure 3.3: Basic Keithley circuit.
3.1.6 Compliance

A compliance facility is installed to protect the circuitry of the DUT. In its voltage source case it is set to limit the current output level. A request voltage will only be supplied if this compliance is not exceeded. If it is, the compliant current will be supplied. Setting the compliance sets the range at which a measurement is displayed. For some DUTs the compliance needs to be large, but some measurements may require smaller scales. In these cases the autorange function is used.

3.1.7 Autorange

Autorange causes the Keithley to automatically select its measurement range, and thus its compliance, to adapt to currents smaller than one ten-thousandth of the DUT’s compliance at that time.

3.1.8 Filter

In order to average the results, the filter function can be used. This allows an average of 2, 4, 8, 16 or 32 readings. Its only disadvantage is that it consumes time for each progressively more precise setting.

3.1.9 Integration Time

This option affects the resolution of the reading as it is taken from an analogue to digital conversion. The longer the integration time (to a maximum of the period of the mains power supply) the broader the bandwidth and therefore the better the measurement resolution.
3.2 The HP4284A

The HP is a device for measuring complex impedances over a range of frequencies and displaying them in a variety of formats. It is needed to measure the capacitance of the DUT.

3.2.1 Capabilities

An AC current is sent through the DUT. Its complex impedance is calculated by comparing the amplitude and phase of the AC voltage across DUT with that of the AC current passing through it. The HP measures impedances in the range 0 Ω to 100 MΩ, whether inductive, capacitive or resistive.

A capacitance can be measured with an accuracy of ±0.05% while a dissipation factor can be measured with an accuracy of ±0.0005. The HP can be set to automatically switch to the most appropriate scale for measurement.

3.2.2 Accurate Measurement Set-up

For accurate measurement the “Four Terminal” set-up is recommended. This is shown in figures 3.4 and 3.5. Other set-ups are referred to in the manual [11].

![Figure 3.4: HP4284A four terminal set-up [11]](image)

A test current is produced through a 100 Ω resistor. This passes down the centre of one metre of coaxial cable ($H_{\text{cur}}$). It is met by the centre of another metre of
Figure 3.5: HP4284A basic measurement circuit layout [11]
coaxial cable ($H_{pot}$) connected to a high impedance voltmeter. Both are connected to the "high potential" end of the DUT.

On the other side of the DUT is a virtual earth created by an amplifier controlled oscillator. The input impedance of the amplifier is large and so essentially no current passes the metre of coaxial cable ($I_{pot}$). The current is directed through an ammeter and the oscillator via one meter of coaxial cable ($I_{cur}$) into the outer of the coaxial cable. All four shields from the cables are connected to the chassis at the DUT end. This allows the two 'pot' terminals to complete their circuits and allows the current to return to the first oscillator.

The magnetic fields created by the current carried by the cables cancel and so the cables are free of inductance. This is due to the equal and opposite currents in the shield and the centre.

3.2.3 Accuracy

The accuracies given in section 3.2.1 are for certain variables and certain circuit set-ups. These are conservative estimates and can be vastly improved by careful apparatus construction, choice of operation (section 3.2.2) and choice of mode (see section 3.2.7).

To calculate the accuracy in the readings, many parameters have to be considered. There are errors relating to the impedance of the device, the cable length, the frequency and the temperature. The manual gives the method for calculation of all scenarios [11]. The accuracy for the set-up used in this thesis is calculated in appendix A This yeilds an accuracy for C and D of 2 ppm for a 10 pF capacitor This is the size of capacitances encountered in this thesis.

3.2.4 Display Type

Two matched variables (see section 3.2.5) are calculated from the complex impedance. These are displayed in a small text box. The basic setup is also visible in this box. This includes the test signal voltage, the test signal frequency, the range, the bias (not used in this thesis), the integration time and a series of menus. The menus are
used for front panel operation.

### 3.2.5 Definition and Grouping of Variables

The variables, which are measurable, are listed in Table 3.2.

<table>
<thead>
<tr>
<th>VARIABLE</th>
<th>DESCRIPTION</th>
</tr>
</thead>
<tbody>
<tr>
<td>$</td>
<td>Z</td>
</tr>
<tr>
<td>$</td>
<td>Y</td>
</tr>
<tr>
<td>L</td>
<td>Inductance (H)</td>
</tr>
<tr>
<td>C</td>
<td>Capacitance (F)</td>
</tr>
<tr>
<td>R</td>
<td>Resistance (Ohms)</td>
</tr>
<tr>
<td>G</td>
<td>Conductance (S)</td>
</tr>
<tr>
<td>D</td>
<td>Dissipation Factor</td>
</tr>
<tr>
<td>Q</td>
<td>Quality Factor</td>
</tr>
<tr>
<td>$R_s$</td>
<td>Series Resistance (Ohms)</td>
</tr>
<tr>
<td>$R_p$</td>
<td>Parallel Resistance (Ohms)</td>
</tr>
<tr>
<td>X</td>
<td>Reactance (Ohms)</td>
</tr>
<tr>
<td>B</td>
<td>Susceptance (S)</td>
</tr>
<tr>
<td>$\theta$</td>
<td>Phase Angle (Rad/Deg)</td>
</tr>
</tbody>
</table>

Table 3.2: Definition of variables

These variables are paired off as follows: $C_p&D$, $C_p&Q$, $C_p&G$, $C_p&R_p$, $C_s&D$, $C_s&Q$, $C_s&R_s$, $L_p&D$, $L_p&Q$, $L_p&G$, $L_p&R_p$, $L_s&D$, $L_s&Q$, $L_s&R_s$, $R&X$, $Z&\theta$ (Rad/Deg), $G&B$, and $Y&\theta$ (Rad/Deg).

The ‘p’ and ‘s’ subscripts refer to the type of measurement mode selected. These are described in section 3.2.7.

### 3.2.6 Calculation of Variables from the Complex Impedance

Table 3.3 below, shows a list of formulae to change between the different variables displayed by the HP.


\begin{align*}
Z &= R + iX \\
Y &= G + iB \\
Y &= \frac{1}{Z} \\
|Z| &= \sqrt{X^2 + R^2} \\
|Y| &= \sqrt{G^2 + B^2} \\
L &= \frac{X}{\pi f} \\
Q &= \frac{|X|}{R} \\
D &= \frac{R}{|X|} \\
R_s &= R \\
R_p &= \frac{1}{Q} \\
C &= \frac{B}{\pi f} \\
\theta &= \arctan \frac{|X|}{R} \\
\phi &= \arctan \frac{|B|}{C} \\
\phi &= -\theta
\end{align*}

Table 3.3: Formulae for the interchange of variables

### 3.2.7 Choice of Mode

Pairs of variables are grouped together in two modes. The choice of mode depends on the type of circuit being measured. In figure 3.6 two basic circuits are shown. In the top circuit the parallel resistance has the most significant effect. In the bottom circuit the series resistance has more influence on the readings. This is due to the value of the reactive impedance of the capacitor (or inductor). High impedance capacitors cause more current to flow through the resistor, \( R_p \), and reduce the potential drop across \( R_s \). Low impedances capacitors increase the voltage seen across the resistor, \( R_s \), and less current is drawn through \( R_p \).
Figure 3.6: Capacitance circuit mode selection [11]
3.2.8 Test Signal

The test signal can be varied from \( 5 \text{ mV}_{\text{rms}} \) to \( 2 \text{ V}_{\text{rms}} \) or from \( 50 \mu\text{A}_{\text{rms}} \) to \( 20 \text{ mA}_{\text{rms}} \). It can also be varied from \( 20 \text{ Hz} \) to \( 1 \text{ MHz} \) in 8610 frequency settings.

3.2.9 Ranging

The HP has many measurement ranges shown on the ordinate axis in figure 3.7. In this figure the areas of good measurement are shown. Using the autorange setting the most effective range is chosen automatically. See fig 3.7 for these operating ranges. The HP recognises when it is no longer able to measure correctly, due to large impedances or bad range settings, and displays an error message.

3.2.10 Trigger

The trigger command forces the HP to make a measurement. It can be triggered internally, externally, via the GPIB Bus (HP-IB) or manually.

3.2.11 Delay

A delay can be set halting any activity from 0 to 60 seconds. This delay is between the trigger and the measurement.

3.2.12 Integration Time

As with the Keithley there is an integration time. This is for analogue to digital conversions. A long integration time lengthens the time required for each measurement, but returns a more precise measurement.
Figure 3.7: Effective region for each measurement range [11]
3.2.13 Average

An averaging function can be used. It allows averaging of 1 to 256 results. Again, higher accuracy increases measurement time.

3.2.14 Notes on Parasitic Effects

Circuit analysis of a single component is only first order if it is modelled as one component. In practice there are many stray capacitances and inductances present. These can cause precision devices such as the Keithley and the HP to oscillate.

3.2.15 Other Considerations

The HP requires 30 minutes warm-up time.

3.3 Guard Box

A guard box was constructed to protect the two devices from damaging and interfering with each other. The circuit diagram for the guard box is shown in figure 3.10.

The HP must not have, for any length time, a DC potential across any of its terminals. The Keithley, which is measuring small currents, does not 'want to see' the test signal of the HP.

To give good current readings the Keithley must be separated from the test signal. This was achieved by placing resistors 330 kΩ in series with the DUT at both ends. The effective circuit seen by the Keithley is shown in figure 3.8.

![Diagram](3.8)

Figure 3.8: Effective DUT seen by the Keithley
To isolate the HP from the bias voltage, supplied by the Keithley, four 1 \( \mu F \) capacitors were connected in series with all four coaxial cables from the HP. The capacitance of the devices measured in this thesis are of the order 10 pF. The effective circuit seen by the HP is shown in figure 3.9. The resulting effect of the 1 \( \mu F \) capacitors on the measured capacitance is about 20 ppm.

![Diagram showing effective DUT seen by the HP4284A](image)

Figure 3.9: Effective DUT seen by the HP4284A

An additional 1 \( \mu F \) capacitor was placed between the Keithley “output HI” and the chassis. This was to allow any diminished signal to pass through a “high frequency short circuit”. The RC time constant value of this is 0.3 seconds. A delay must be placed when a new bias voltage is selected. This is set via remote control.
Figure 3.10: Purpose-built guard box
Chapter 4

Computer Code Used

The program codes listed in this chapter are used to operate the HP and the Keithley via remote control. The higher level programs are listed in appendix B. Icons to the right of some of the descriptions below correspond to these diagrams. The programs allow many measurements to be taken with many different settings and ranges whilst the operator is not present.

Using these Labview programs the user can operate the HP and Keithley with greater ease and less direct contact. This is a vast improvement on the front panel operation of the two devices. The major advantage, however, is the ability to store data, adjust data and move data via the ethernet.

The labview programming interface is picture-based. There are two displays, one of which has a “circuit” type view and the other a user-designed “front panel” interface. These are displayed in two windows.

The circuit view shows the operation of the program. Here, icons are linked together by wires to either other icons, starting points or terminations. Each wire can carry information, from logic values up to clusters of arrays, numbers, bits and bytes.

The front panel interface is used to enter the values of the starting points and display the values of the terminations. It can display numbers, strings, clusters, graphs of many types, dials, knobs, buttons, etc.
CHAPTER 4. COMPUTER CODE USED

Understanding how a program runs is a relatively easy task. There is an option to view the program as it is running by animation in the circuit window. The values of the data carried by the wire can be displayed by using a ‘probe’. A probe produces a window which displays the data on a wire chosen by the user.

4.1 The Main Code

This section covers the actions of the high level, “front panel”, programs. These are the programs that the user deals with directly. They call the other pieces of code as and when required.

The Controlling Program to Test Three Frequencies

This program is named “Test4ThreeFrequencies.vi”. Figures B.1 and B.2, in appendix B, show the layout of this program. It is designed to run the Voltage, Current and Capacitance Subroutine, “VICSubVi.vi” below, for three frequency settings. It allows the user to choose these frequencies. The user must specify whether current and/or capacitance is to be measured, what voltage range, the number of steps and whether a logarithm scale is required. A caption facility is also present to tag to the three sets of readings.

All the data gathered are mailed with the captions, as three separate files, to an email address. These files carry the data for each frequency. All the information is saved to a log file on the Macintosh in case of a bad mail connection.

The Voltage, Current and Capacitance Subroutine

This program is called “VICSubVi.vi” and is displayed in figures B.3 to B.8 of appendix B.

This file is the major controlling section of the whole operation. It can be used on its own or with a controlling labview program such as “Test4ThreeFrequencies.vi”. A previous version was designed by Julian Freestone [12] which cannot be controlled
by a separate program and does not mail the results. These programs are similar in most other aspects of their performance but rather different in their encoding.

The program determines which measurements are to be taken and what scale is required from the front panel or the controlling program. It then sets up the header for the data files which will be sent and recorded (figure B.3). Following this the program requires the probe not to be in contact with the DUT if an “open circuit value” has been requested (figure B.4). If it has, the requested results are then taken (using main Keithley and HP operating codes, below). They are then added to a register (figure B.5). The program then requests the probe to be placed in contact with the DUT (figure B.6). Readings with a zero bias are then taken as before and registered (figure B.7). An incremental loop is run where the voltage changes between each reading. This terminates after a set number of readings and all data is duly registered (figure B.8 top). Finally the data is sent via email (figure B.8 bottom).

The Main Keithley Operating Code

The main Keithley operating code, “Kth-SvMi_Main.vi”, is given the request voltage, which it relays to the Keithley. The Keithley returns the value of the corresponding current drawn by the DUT (see figures B.9 and B.10).

The code relays the current by using the following procedure and code listed in section 4.2: the Keithley is reset, then the basic configuration is invoked with a 1 mA current compliance. It is set to supply voltage and measure current. Its autorange is activated. It is set to average 32 readings, to integrate over 20 ms, to sense remotely and is set not to sweep. It is also set to work within the 1100V range. The Keithley is taken off stand-by mode (section 4.2). The voltage is sent and the Keithley is triggered to supply this. There is then a 20 second delay to allow the electronics to settle. The voltage and current are then read. Finally the value of the current is passed back to the calling routine.
CHAPTER 4. COMPUTER CODE USED

The Main HP4284A Operating Code

The HP operating code, “HP_getdata_main.vi”, is supplied with values for the test frequency, the running average and the type of reading. Using code in section 4.3 it returns values for two components describing the complex impedance measured by the HP.

Firstly the HP is reset. Then the basic configuration is set up. After this the aperture is set, which adjusts the integration time and averaging rate. Next, a single reading is made in accordance with the type of reading passed. Finally the HP is reset.

During the set-up autorange is switched on, the cable length is set to 1m and the integration time is set to medium. The code returns two readings with double precision.

4.2 The Keithley Code

The Operate/Standby Switching Code

This code expects one bit of information. A true bit sends a switch-on command to the Keithley. A false bit sends a switch-off command.

The Measurement Taking Code

This code can cope with either a DC reading or a set of readings from a sweep routine. This project only requires the DC operation. The Keithley’s GPIB address is taken and the code requests that the Keithley take a measurement. The measurement is returned in the first two arrays in a cluster of arrays. Both current and voltage are returned in ascii format.
CHAPTER 4. COMPUTER CODE USED

The Code to Set the Basic Configuration

The basic config routine allows the following to be set: voltage range, compliance, integration period, filter (number of readings to be averaged), source level, remote/local measurement variable, type of measurement variable (source V measure I or the other way around), function variable (DC/sweep), the autorange function, and the in-built delay system. It only returns error information.

The Code to Send the Reset Command

This function resets the Keithley back to the manufacturer’s specifications.

The Code to send the Trigger Command

This triggers the Keithley to accept information.

The Code to Set the Bias Voltage

This function sets the bias without having to send all the basic set-up information again. It allows the range and delay variables to be altered.

The Code for Receiving Data from the Keithley

This is the same as the GPIB receive message function. It allows information to be received from the GPIB interface. If a number is passed to this function then it will wait to receive that many bytes. If 0 is passed it will wait until the full packet of information has been received.
CHAPTER 4. COMPUTER CODE USED

The Code for Sending Data to the Keithley

This is used to send ascii information via the GPIB interface.

The Data Handling Routine for the Keithley

This subroutine is called "forfilenum.vi". It takes the Keithley's readings in numerical form and puts them into a string in ascii form to be exported. The resulting string is for the emailing process.

4.3 The HP Code

The Code for Setting the Aperture

The aperture is a Hewlett Packard term meaning the precision setting. This code sets the averaging rate (0 to 255 times) and the integration time (short, medium or linecycle) of the HP.

The Code Used for sending the Reset Command

This function sends the reset command to the HP. This causes the HP to revert to its initial state programmed by the manufacturer.

The Code for Starting the Measurement

The single read function sends a request to the HP for the measurements that the HP is set up for. There are two measurements. These are put into numerical format and returned to the calling routine as an array of two double precision floating point numbers.
CHAPTER 4. COMPUTER CODE USED

The Code for initialising the HP4284A

This code allows the function, range, integration time, average and frequency to be set.

The Data Handling Routine for the HP4284A

This subroutine is called “HP_Data.vi”. It takes the HP's readings in numerical form, turns them into an ascii scientific form and puts them into an ascii string. The string is passed on for emailing etc.

4.4 Other Code

Data Outputting to File

This code used for this causes a file to be created and written to. The name of the file is determined by a string passed to the function and by the time and date at the point when this function is executed.

The Email Function

This function sends an email message containing the results in the form of a string to a specified email address. It uses a TCP/IP link to port 25 of a computer at a specified IP address. This function is not very portable.

The Comparator Function

This is used in the email function to create an error message if any of the TCP/IP packets are not what they are expected to be.
The TCP/IP Search Function

This searches a TCP packet for a certain string passed to it. It is a subroutine of emailing function.

All other code used is standard in the full installation of Labview.
Chapter 5

Experimental Procedure

Two things are recorded in this chapter. Firstly, the assembly of the individual components is described. The second section describes the procedure for testing the set-up and measuring the silicon detectors.

5.1 The Experimental Set-up

With the information from chapter 3 the experimental set-up can be explained with a black box approach. A diagram of the apparatus can be seen in figures 5.1 and 5.2. The apparatus in figure 5.2 is that which is located in the Faraday chamber.

5.1.1 The Faraday Chamber

The Faraday chamber serves two purposes. Firstly, since it is made of metal it shields the probes inside from external electrical interference. Secondly, it is opaque. A dark environment is required as light incident on the silicon promotes its electrons into the conduction band. This light frees electrons in the depletion region and thus spoils any results taken.
CHAPTER 5. EXPERIMENTAL PROCEDURE

Figure 5.1: The set-up (exterior)

Figure 5.2: The set-up (inside the Faraday chamber)
5.1.2 The Probe Station

This is an electronically assisted x, y movement station with a vacuum chuck fitted to it. It has a metal plate where the silicon diode is able to be held by suction. Around the vacuum chuck is a raised steel annular disk. This is used to mount magnetic-based probes on. These probes are small x, y, z microscopic movement devices which allow the probe needle to be moved small distances with ease. As the probes have their own x, y, z movement the x, y movement of the probe station is not required.

Above the vacuum chuck is a microscope with lighting supplied by optical fibre. This is used to find the right position for the probe needle.

A Peltier effect device is located under the vacuum chuck. Its hot side is irrigated with water to cool down the DUT. The cooling device was not used in this project.

5.1.3 Assembly of the Electronics

Figure 5.1 shows the data link between the various electronic devices and their routes to the mains.

The Keithley’s three triaxial cables and the HP’s four coaxial cables pass into the Faraday chamber. None of the wires are in contact with the metal of the chamber. The location at which the cables pass through into the chamber is guarded against any leakage of light.

Inside the chamber the seven cables are connected to the purpose-built guard box. The outer edge of this box is connected to the Faraday box to earth it. The two coaxial cables leaving the box go to the probe station. The high potential end goes to the probe needle and the low potential end goes to the metal vacuum chuck.

5.2 The Experimental Procedure

The experiment is in two sections, the first is the testing of the apparatus developed, using circuits whose behaviour can be predicted. The second section is the taking
of measurements on the silicon strips and silicon diodes with and without glue.

Both sections require an open circuit measurement. This is done to allow subtraction of the parallel capacitance of the system. To take this measurement the contact to the DUT is just broken. In the case where the probes are used the probe is lifted a small amount from the contact point.

5.2.1 Testing the Apparatus

To establish whether the apparatus would take accurate measurements of depletion voltage and leakage current, tests on ‘simple’ circuits where carried out. The measurements of capacitance and of current were taken on different DUTs. The DUTs chosen were resistors, resistors and capacitors in parallel, capacitors, and basic silicon diodes.

Of all the DUTs, only the silicon diodes were able to sit on the vacuum chuck. Therefore a device was constructed to hold the DUT, and to allow both coaxial cables from the ‘box’ to be connected. This can be seen in figure 5.3.

The capacitance of the test silicon diodes can be derived from their size. This
allows a choice of capacitor for the basic tests. The test diode has a plate area of 25 mm$^2$ and is 330 microns in depth. The capacitance, from equation 2.9, is therefore approximately 10 pF. A 10 pF capacitor was chosen for the readings.

The resistors chosen were of very large resistance, as the readings for the leakage current in the detector are very small. 500 MΩ, 1 MΩ and 100 kΩ resistors were used.

The three frequency test program was used to take the measurements. The frequencies used were 10 kHz, 100 kHz and 1 MHz. The results for these tests are listed in chapter 6.

### 5.2.2 Taking the Measurements on Silicon Devices

Two different set-ups were used. The vacuum chuck method was used for the silicon wafers. A method, described below, was used to take results for the glued DUTs. It became apparent that this method produced results which fitted those expected for the test diodes better than the vacuum chuck method. This method was adopted for all subsequent measurements.

Measurements were made on several 25 mm$^2$ silicon diodes, on one silicon 25 mm$^2$ before and after gluing and on one strip detector diode.

The vacuum chuck set-up was used to take measurements of the silicon 25 mm$^2$ diode and the strip detector diode. The diodes were placed on the vacuum chuck and the probe placed close above the point of contact (in the case of the silicon strip detector, just above the strip being measured). The Labview three frequency test program was used. As and when required by the program the Faraday chamber was opened and the probe moved to make contact or break contact. This was only required at the beginning of the program.

The experiment ran unmanned after the computer had finished receiving information from open circuit readings. The results were collected and emailed within two hours. (It is possible to reduce this time by choosing a single frequency, lowering the accuracy and taking fewer results).

The gluing process was investigated by gluing a diode to a glass microscope
slide. The conditions before and after gluing must be identical, so the glass had to be present throughout.

Using the glass it was no longer possible to place the diode on the onto the vacuum chuck and have an electrical contact.

Another probe needle was used. This time the needle was bent upwards and made contact with the underside of the diode. The diode was placed on two sheets of glass, separated horizontally by about 1 mm so that the probe could make contact. This is shown in figure 5.4.

![Figure 5.4: The glued diode set-up](image)

**Glue**

The glue used was an epoxy resin with aluminium oxide powder in it. This is one of the glues under consideration for the final detector. The glue consists of 4 parts Al₂O₃, 4 parts hardener and 5 parts epoxy resin.

### 5.3 Measurement Difficulties

During the setting up of the apparatus and its earlier test runs a major problem was uncovered. The HP was programmed to sweep through a list of frequencies continuously. These were read when the computer was ready. Current measurements taken at the same time as the HP was sweeping caused up to 100 nA fluctuations
with no ascertainable periodic information. The majority of these fluctuations were all of the same amplitude. The exact origin of this phenomenon is still unknown.

To combat this problem the size of the resistors in the box was changed to see if this would make an improvement. It caused no reduction in the signal to noise ratio.

The list sweep operation of the HP was then turned off to see if this reduced the errors. This resulted in the frequency of the fluctuation changing. The spikes on the current were further apart but still many results were spoiled.

The final change, which removed these spikes, was when an extra reset command was placed after the HP had taken its measurements. This rendered the HP in a state of basic configuration while the current measurements were taken.

The possible areas of conflict are talk between the HP and Keithley through the circuit or interference over the GPIB interface (The GPIB cables are at the maximum recommended length).
Chapter 6

Data Analysis

6.1 Method for Data Analysis

The data arrives in the format shown in figure 6.1 over-leaf. All text is tab delimited and so all the results can be read straight into a spreadsheet.

Such a spreadsheet was constructed. On receipt of data it calculates \( \frac{1}{\sqrt{|V|}} \) and \( \ln |V| \) for each voltage. It takes the zero bias current from all current readings and take the open circuit capacitance from all the capacitances. The latter assumes that all parasitic capacitative effects are in parallel with the DUT.

All values of current are values through 660 kΩ of resistors as well as the DUT. The DUT ‘sees’ a reduced potential difference due to the two 330 kΩ resistors in the purpose built guard box. The voltage across the DUT is therefore \( V_m - (I \times 660 \times 10^3) \) V, where \( V_m \) is the voltage across the DUT and guard box. In the low current situations where the equivalent DUT resistance is very high, the measured voltage is almost completely across the DUT. This is the case for the silicon diodes but not for the other DUTs.

A value for \( V_{dep} \) is measured where a change in the relationship between the capacitance and bias voltage is observed. This can be seen when the capacitance varies with either \( \ln |V| \) or \( \frac{1}{\sqrt{|V|}} \). See section 7.1 for a fuller discussion.
From Labview@hepmail.ph.man.ac.uk Sun 5 Oct 21:57:21 1997

Date: Tue, 16 Sep 1997 13:43:33 +0100 (BST)

From: Labview@hepmail.ph.man.ac.uk

strips at 10kHz

V  I  Op  G

Open Circuit
0.000000E+0  5.730000E-12  654.591000E-15  -45.996700E-12

Zero Bias
0.000000E+0  -4.430000E-12  946.797000E-15  7.682590E-9

Results
0.000000E+0  1.580000E-12  934.552000E-15  6.366890E-9
-1.000000E+0  -52.180000E-12  913.420000E-15  2.527350E-9
-2.000000E+0  -80.280000E-12  963.638000E-15  4.157140E-9
-3.000000E+0  -85.060000E-12  2.624610E-12  233.909000E-9
-4.000000E+0  -111.870000E-12  7.281560E-12  258.546000E-9

Figure 6.1: The format of the output data
6.2 Simple Test DUTs

6.2.1 The 100 kΩ Resistor DUT

Figure 6.2: A 100 kΩ resistor

From the current plot in figure 6.2 it can be seen that the device is ohmic. A resistance of \(\frac{100}{133 \times 10^6}\) Ω, which is 752 kΩ, was measured for the device and guard box. The DUT’s resistance is calculated to be 91.9 kΩ, as the guard box has a resistance of 660 kΩ. This is constant over each HP frequency setting as expected.

Value of \(C_p\) from the HP are very small due to the presence of no capacitors.
6.2.2 The 1 MΩ Resistor DUT

Figure 6.3: A 1 MΩ resistor

Figure 6.3 shows the expected ohmic response. The resistance of the DUT is \( \frac{100}{60 \times 10^{-6}} - (660 \times 10^3) \) Ω which gives 1.006 MΩ. The capacitance reading is negligible.
6.2.3 The 1 MΩ Resistor & 10 pF Capacitor in Parallel

Figure 6.4: A 1 MΩ and a 10 pF capacitor in parallel

Figure 6.4 shows the resistance, as expected, to be 1.006 MΩ. However, since there is a capacitor, $C_p$ is evaluated as 10.216 pF, 10.227 pF and 10.269 pF for the 10 kHz, 100 kHz and 1 MHz HP settings respectively.
6.2.4 The 500 MΩ Resistor & 10 pF Capacitor in Parallel

Figure 6.5: A 500 MΩ and a 10 pF capacitor in parallel

Figure 6.5 shows the DUT’s resistance to be 499.34 MΩ at 100 kHz and 1 MHz and 516.01 MΩ at 10 kHz. The capacitances are measured to be 10.153 pF for the 10 kHz setting, 10.142 pF for the 100 kHz and 10.147 pF for the 1 MHz setting with errors, calculated from equation A.1 in chapter 3, of ±0.002 pF.

Conclusion

The measurements of capacitance and current above show that the set-up will be capable of measuring the types of impedances inherent in the silicon diode DUTs.
6.3 Silicon Test DUTs

6.3.1 The First Silicon 5 mm Square Diode

![Figure 6.6: The silicon 5x5 diode No.1](image)

It can be seen in figure 6.6 that the current readings are swamped by interference. These results have been taken without the corrections later added to the Labview program. For comments on this refer to section 5.3.

The capacitive properties can easily be seen. Equation 2.9 gives an expected value of capacitance for this DUT as $C = 7.89 \, \text{pF}$ when it is fully depleted, given that the area of the silicon is $A = 25 \, \text{mm}^2$ and its depth is measured, using a micrometer, to be $D = 331 \, \mu\text{m}$. As the bias voltage becomes greater than the depletion voltage the capacitance should take this value. It is measured to be 7.619 pF after depletion.

The knee of the curves give a $V_{dep}$ of about 27 V.
6.3.2 The Second Silicon 5 mm Square Diode

![Graphs showing capacitance vs $1/\sqrt{|V|}$ and $\ln|V|$ for different frequencies: 10 kHz, 100 kHz, and 1 MHz.]

Figure 6.7: The silicon 5x5 diode No.2

Again these results were taken using the Labview program where the HP was active during the current readings. From figure 6.7 the maximum value for $V_{dep}$ is measured to be $52 \text{ V}$ from the $1/\sqrt{|V|}$ graph and $44 \text{ V}$ from the $\ln|V|$ graph. The knee is at a value of $33 \text{ V}$ to $36 \text{ V}$. The capacitance at depletion is $7.857 \text{ pF}$. 
6.3.3 The Third Silicon 5 mm Square Diode

Figure 6.8: The silicon 5x5 diode No.3

Figure 6.8 shows the value for $V_{dep}$ to be 40 V at 10 kHz and 57 V at 1 MHz from the $\frac{1}{\sqrt{|V|}}$ graph and 41 V at 10 kHz and 34 V at 1 MHz from the ln $|V|$ graph. The capacitance at depletion is 8.57 pF and the leakage current is about 0.16 $\mu$A.

These results and all hereafter have been taken with an extra HP reset command prior to current measurement (see section 5.3).
6.4 Silicon DUTs Before and After Gluing

6.4.1 Glass Platform with Unglued Silicon 5 mm Square

The data in figure 6.9 have the characteristics expected for a diode. The leakage current of the diode is measured to be 1.603 μA. The capacitance is measured to be 9.52 pF. The depletion voltage is 26 V from the log scale and 22 V from the $\sqrt{\frac{1}{|V|}}$ scale graph.
6.4.2 The Glued Silicon 5 mm Square Diode on Glass

The $25 \text{ mm}^2$ silicon diode whose results are shown in figure 6.10 was measured with all the same conditions as the unglued silicon on glass diode on the previous page as well as having been glued to a glass plate. The depletion voltage is measured to be 29 V on the log graph and 28 V on the $\frac{1}{\sqrt{V}}$ graph. The capacitance at depletion is 11.4 pF. The leakage current now varies over the range 1.5 to 4 µA with the 1 MHz and 100 kHz test signals and 1.5 to 2.5 µA with the 10 kHz test signal.

Conclusion

There is a clear change in the characteristics of the leakage current as a result of the gluing process. These is an additional leakage current which is more pronounced at larger voltages.
6.4.3 The Fourth Silicon 5 mm Square Diode

These data (shown in figure 6.11) were taken using the glass slide technique. This was done because the results from the diode in the gluing experiment had better characteristics. The figure depletion voltage for the fourth diode is 21 V and 22 V from the two graphs the latter being from the logarithm graph. The capacitance, 11.11 pF, is sensible. The leakage current is 1.5 μA tailing off to 2 μA at high voltages. All consequent data has been taken using the two probe method.
6.4.4 Silicon Strip 1

Figure 6.12: The silicon 10 micron strip detector (4 cm long)

Figure 6.12 shows the data taken whilst measuring the 10 micron strips on the wafer shown in figure 6.13. This was done using the two probe method. This device only has structure on the top side where the strips are. The depletion voltage is measured to be 20 V. The leakage current is measured to be 4.5 nA. The capacitance, at depletion, is measured to be 8.21 pF.

There are three sets of strips all too small to be shown here. Each set has strips of one width differing from the other two sets.

Figure 6.13: The silicon 10 micron strip detector No.1
6.4.5 Silicon Strip 2

Figure 6.14: The silicon 10 micron strip detector (3.8 cm long)

Another silicon strip diode (figure 6.15) was measured. This was done using the two probe method. This device only has structure on the top side where the strips are. From data shown in figure 6.14 the depletion voltage is measured to be 57 V for the 1 MHz reading and 61 V for the 10 kHz reading. The leakage current is measured to be 1.43 μA. The capacitance, at depletion, is measured to be 3.148 pF.

The leakage current increases with the bias voltage below -60 V this could be the start of the diode reverse-bias-breakdown (see figure 2.2).

Figure 6.15: The silicon 10 micron strip detector No.2
Chapter 7

Discussion

7.1 Measurement of Depletion Voltage

To find the value of depletion voltage for a silicon diode the data from the measurements of capacitance over the range of voltages must be analysed. These data fit two lines. The solution satisfying both of these lines (the knee) is difficult to find with good accuracy. The line where the capacitance is constant is an easy fit because of its equation $C = \text{Constant}$ but the varying capacitance line appears to fit sometimes two different lines. Some thought into the data analysis of this fit may be required for better results.

7.2 Computer Code Development

All the code described in this thesis works enough to cover the measurements taken. However, the program “Test4ThreeFrequencies.vi” was constructed loosely. Running this code requires the user to place a contact onto the DUT two times more than necessary. Also, when running the log scale result taking routine there is one extra result taken than is requested. To save time both these faults can be rectified. This can be done with relative ease.
7.3 Cold Measurements

To test the silicon strips that have been irradiated the temperature of the silicon strip must be kept below $-5^\circ$C. As mentioned earlier the silicon wafer would form ice crystals on its surface by condensing the water vapour out of the gas surrounding the diode. A way to enclose the DUT within its own dry atmosphere would have to be found. A possible solution might be to fit the probe station inside a glove box and fill this with nitrogen gas.
Chapter 8

Conclusion

The objective of this thesis has been reached. The set-up will measure leakage currents to an accuracy of ±0.01 nA, and depletion voltages to an accuracy of about ±1 V extracting data by eye.

The apparatus developed has been tested. A labview program has been developed to control all the operation except the physical movement of devices and probes, and the data analysis.

The gluing process was tested and a change in the characteristics of the leakage current was observed. The leakage currents measured after the gluing process were larger than those measured before gluing. The amount by which the I-V characteristics depart from those measured before gluing increase with bias voltage.

The leakage current for a silicon strip from a test device has been measured to be 1.40 ± 0.01 nA and the depletion voltage measured was 57 ±1 V.
Appendix A

Accuracy of the HP4284A

The accuracy of the HP [11] for the measurements recorded in this thesis is given by

\[
\sigma = \left( \frac{A}{100} + 100 \left( k_a + k_{aa} + (k_b \times k_{bb}) + k_c \right) + \frac{k_d}{100} \right) k_e, \quad (A.1)
\]

where:

\[
A = 0.05 \\
k_a = 3.21 \times \left( \frac{10^{-3}}{|Zm|} \right) \\
k_{aa} = 0 \\
k_b = |Zm| \times 1.07 \times 10^{-8} \\
k_{bb} = \begin{cases} 1.5 \text{ at } 1 \text{ MHz} \\ 1.2 \text{ at } 100 \text{ kHz} \\ 1.05 \text{ at } 10 \text{ kHz} \end{cases} \\
k_c = 0 \\
k_d = \begin{cases} 0.01275 \text{ at } 1 \text{ MHz} \\ 1.5 \times 10^{-3} \text{ at } 100 \text{ kHz} \\ 3.75 \times 10^{-4} \text{ at } 10 \text{ kHz} \end{cases} \\
k_e = 1 \text{ for } 18^\circ \text{C} < T < 28^\circ \text{C}
\]

and, \( |Zm| \) = The impedance of the DUT.
This applies to values of Z, Y, L, C, R, B, X and G (when measuring G&B together). Errors for D, Q, θ, G (in all other cases), R_p and R_s can be calculated as follows:

\[
\begin{align*}
\sigma_D &= \frac{\sigma_{\theta}}{100} \\
\sigma_Q &= \frac{\sigma_D^2}{1 + Q_{\sigma_D}} \\
\sigma_{\theta} &= \frac{\sigma_{\theta}}{100} \text{ [rads]} \\
\sigma_G &= \frac{1}{X} \sigma_D \text{ [S]} \\
\sigma_{R_p} &= \frac{R_p \times \sigma_D}{D \times \sigma_D} \text{ [Ω]} \\
\sigma_{R_s} &= X \times \sigma_D \text{ [Ω]}
\end{align*}
\]

This gives an error for C as ±2 × 10^{-4} % and D as ±2 × 10^{-6} for a 10 pF capacitor.
Appendix B

Labview Coding for Experiment Control

The following diagrams are print-outs from the higher level Labview programs. They are intended for those who know the language. The following programs are listed: Test4ThreeFrequencies.vi, VICSubVi.vi, Kth-SvMi_Main.vi, and HP_getdata_main.vi.
Figure B.1: Test4ThreeFrequencies.vi (part 0)
Figure B.2: Test4ThreeFrequencies.vi (parts 1, 2 & 3)
Figure B.3: VICSubVi.vi (part 0)
Figure B.4: VICSubVi.vi (part 1)
Figure B.5: VICSubVi.vi (part 2)
Figure B.6: VICSubVi.vi (part 3)
Figure B.7: VICSubVi.vi (part 4)
Figure B.8: VICSUBVI.vi (parts 5 & 6)
Figure B.9: Kth-SvMi_Main.vi (part 1)

Figure B.10: Kth-SvMi_Main.vi (parts 2 & 3)
Figure B.11: HP \textit{getdata\_main.vi}
References


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REFERENCES


